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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/790,800	03/03/2004	Masao Tomikawa	360842006010	4377
25227	7590 06/28/2006		EXAMINER	
MORRISON & FOERSTER LLP			CHU, JOHN S Y	
1650 TYSON	S BOULEVARD		I now to the	D. 200 ) II I (200
SUITE 300			ART UNIT	PAPER NUMBER
MCLEAN, V	A 22102		1752	
			DATE MAILED: 06/28/2006	6

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)			
Office Action Summany	10/790,800	TOMIKAWA ET AL.			
Office Action Summary	Examiner	Art Unit			
	John S. Chu	1752			
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the	correspondence address			
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA  - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication.  - If NO period for reply is specified above, the maximum statutory period w  - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATIO 36(a). In no event, however, may a reply be tivil apply and will expire SIX (6) MONTHS from a cause the application to become ABANDON.	N. imely filed  In the mailing date of this communication.			
Status					
1) Responsive to communication(s) filed on 31 M	ay 2006.				
2a) This action is <b>FINAL</b> . 2b) This action is non-final.					
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims					
4)⊠ Claim(s) <u>1,2,4,9-12 and 14-22</u> is/are pending in the application.					
4a) Of the above claim(s) is/are withdrawn from consideration.					
5) Claim(s) is/are allowed.					
6)⊠ Claim(s) <u>1,2,4,9-12 and 14-22</u> is/are rejected.					
7) Claim(s) is/are objected to.					
8) Claim(s) are subject to restriction and/or	election requirement.				
Application Papers					
9) The specification is objected to by the Examine	r.				
10)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.					
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).					
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).					
11) The oath or declaration is objected to by the Ex	aminer. Note the attached Office	Action or form PTO-152.			
Priority under 35 U.S.C. § 119					
12) Acknowledgment is made of a claim for foreign	priority under 35 U.S.C. § 119(a	ı)-(d) or (f).			
a)⊠ All b)☐ Some * c)☐ None of:					
1. Certified copies of the priority documents have been received.					
2. Certified copies of the priority documents have been received in Application No					
3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).					
* See the attached detailed Office action for a list of the certified copies not received.					
and and detailed enter a list of the certified copies flot received.					
Attachment(c)					
Attachment(s)  1) Notice of References Cited (PTO-892)	4) 🔲 lata-dan 0	(PTO 442)			
1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) Paper No(s)/Mail Date					
3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	5) 🔲 Notice of Informal F	Patent Application (PTO-152)			
U.S. Patent and Trademark Office	6)				
	tion Summary Pa	art of Paper No./Mail Date 20060622			

Application/Control Number: 10/790,800 Page 2

Art Unit: 1752

## **DETAILED ACTION**

This Office action is in response to the RCE filed May 31, 2006.

## Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 2. Claims 1-2, 4, 9-12, and 14-22 are rejected under 35 U.S.C. 102(b) as being clearly anticipated by OBA (5,585,217).

The claimed invention is drawn to the following:

17. (Previously Presented) A positive-working photosensitive resin precursor composition containing (a) a polymer in which structural units of the kind denoted by general formula (1) below are the chief component and (b) a photoacid generator, and the total carboxyl groups contained in said polymer is from 0.02 to 2.0 mmol/g:

wherein one of the following conditions (A) and (B) is satisfied:

- (A) a residual chlorine ion concentration is 30 ppm or less, or
- (B) a residual quantity of sodium, potassium and iron ions is 10 ppm or less,

wherein  $R^1$  is an organic group of valency from 3 to 8 having at least 2 carbon atoms,  $R^2$  is an organic group of valency from 2 to 6 having at least 2 carbon atoms,  $R^3$  is hydrogen or a monovalent organic group with from 1 to 10 carbons but it is not all hydrogen nor is it all a monovalent organic group with from 1 to 10 carbons. n is an integer of value from 3 to 100,000, m is 1 or 2, p and q are integers of value from 0 to 4 p + q > 0, and

wherein some of the carboxyl groups of the polymer represented by general formula (1) are imidized by reaction with an adjacent amide group, and the percentage such imidization is from 1% to 50% of said carboxyl groups of the polymer represented by general formula (1).

Application/Control Number: 10/790,800

OBA anticipates the claimed invention at Example 3 found in column 27, line 40-28, line 25. The example discloses a mixture of a polyamic acid resin and a polyimide resin as the binder and a photosensitizer. This disclosure meets the claimed positive working photosensitive resin of claim 17 comprising a polymer of formula (1), and a photoacid generator. The disclosure in claim 17 for the carboxyl groups of general formula (1) which are imidized and the percentage is from 1% to 50% is met by the disclosed blend of a polyimide in Example 3 of OBA. Here the polyimide is present in an amount of about 7% which would meet the claimed percentage of imidization of 1% to 50% as claimed. Polymer resins in a composition are made up of many polymer chains and the blend as recited in OBA et al would be identical to the recited polyamic acid having a percentage of the polymer chains imidized.

Because OBA discloses a blend of polymer chains, each of the polymers when precipitated, would remove any impurities such as chlorine, sodium, potassium and irons ions. Thus the reference is asserted to meet the claimed ion concentration.

- 3. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. OBA (5,753,407) is cited of interest and is cumulative to the '217 reference having the same disclosure because '407 is a continuation of OBA '217.
- 4. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Examiner Chu whose telephone number is (571) 272-1329. The examiner can normally be reached on Monday Friday from 9:30 am to 6:00 pm.

If attempts to reach the Examiner by telephone are unsuccessful, the Examiner's supervisor, Cynthia Kelly, can be reached on (571) 272-1526

The fax phone number for the USPTO is (571) 273-8300.

Application/Control Number: 10/790,800

Art Unit: 1752

Information regarding the status of an application may be obtained from the Patent

Application Information Retrieval (PAIR) system. Status information for published applications
may be obtained from either Private PAIR or Public PAIR. Status information for unpublished

system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR

applications is available through Private PMR only. For more information about the PAIR

system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

John S. Chu

Primary Examiner, Group 1700

Page 4

J.Chu June 23, 2006